



Innovative Backside Illuminated Single photon imaging sensor

INFN CSN5 project (2021-2022)

Units: Bologna, TIFPA-FBK, Torino

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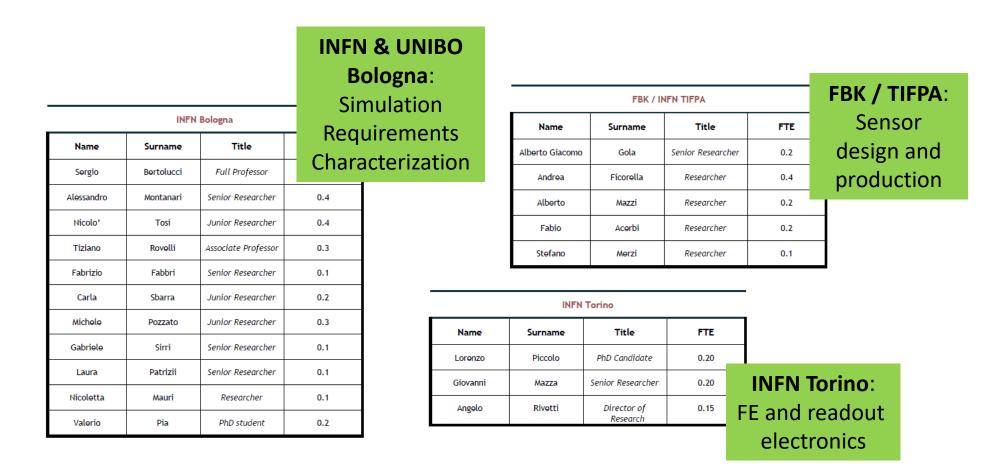
Target

- □ Development of a sensor that coupled to an appropriate optics perfoms fast and high-resolution imaging on a wide range of wavelengths
- ☐ Ideal sensor:
 - High PDE in VUV (or NIR)
 - Small cell size (High dynamic range)
 - Single photon counting (Low light)
 - High speed
 - Integrated readout
- ☐ Application of our interest:
 - Imaging with scintillation light
 - Liquid Argon detectors
 - Scintillators



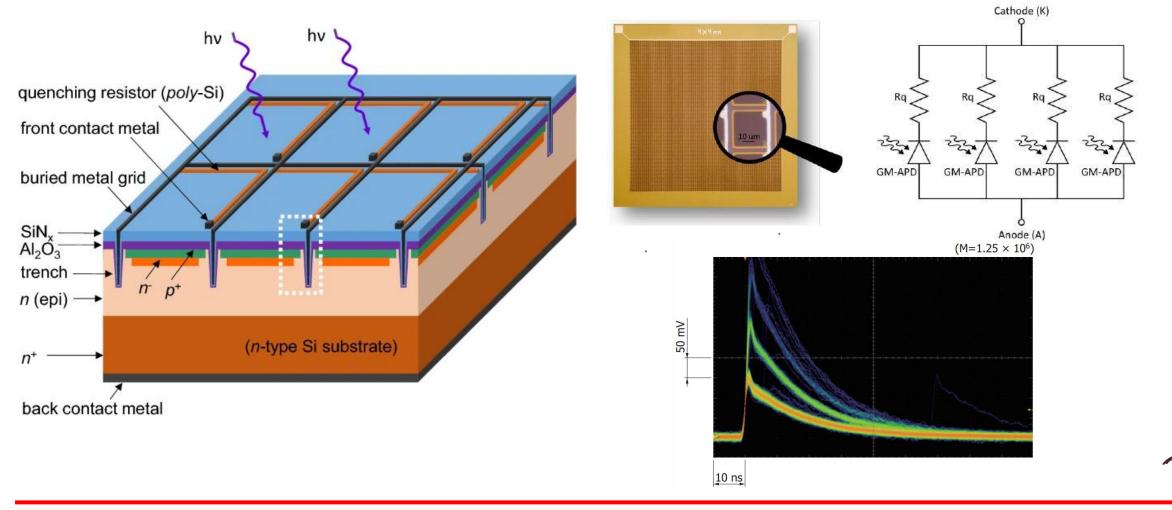
The goal and the team

□ IBIS is focused on the development of an innovative SiPM architecture, as key technology for a new imaging device:

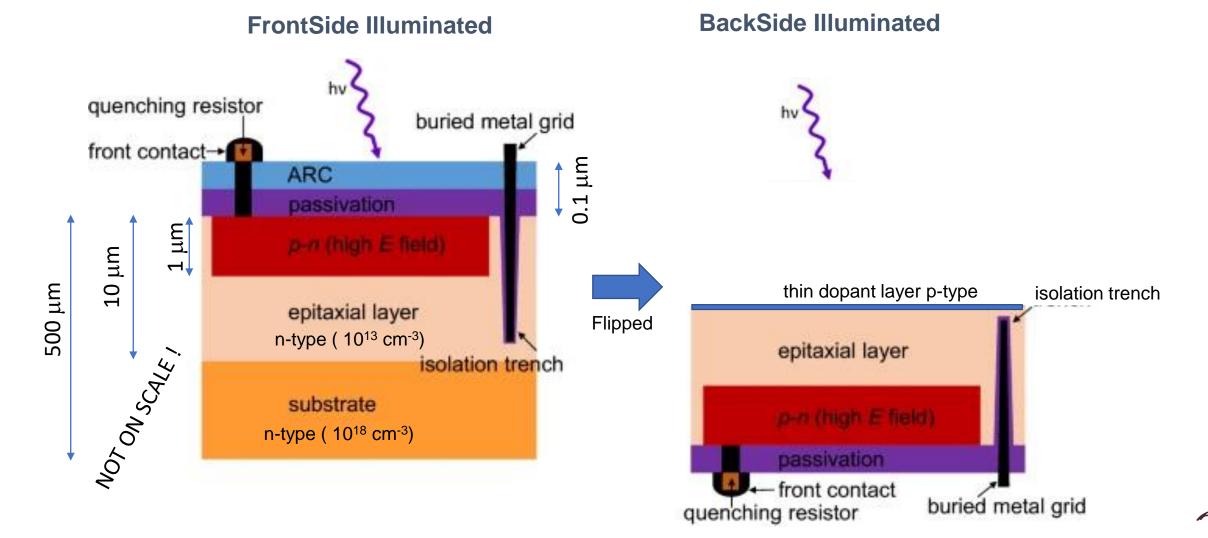


The standard SiPM

- ☐ A set of Geiger avalache photodiodes (SPAD) connected in parallel
 - the analog output is «linearly» proportional to number of impinging photons



What is a Backside Illuminated SiPM?



State of the art

- ☐ A lot of interest about Backside Illuminated:
 - Max Plank Institute: no news since prototype built in 2007
 - TCAD simulations, but no prototype
 - Innovative Anti Reflective Coating (ARC) for Backside, but no prototype
 - A matrix of BSI-SiPM for LiDAR

OPEN Advanced antireflection

Yuguo Tao™, Arith Rajapakse & Anna Erickson

light

for back-illuminated silicon

Nuclear and Radiological Engineering, Georgia Institute of Technology, Atlanta, GA, USA. email: yuquo.tao@

photomultipliers to detect faint

• ...??

31 January 2020

64x48 pixel backside illuminated SPAD detector array for LiDAR applications

Jennifer Ruskowski Charles Thattil Jan H. Drewes Werner Brockherde

www.nature.com/scientificreports

Scientific reports

lectronics and Photonics XVII; 1128805 (2020)

| States



Development of Back Illuminated SiPM at the MPI Semiconductor Laboratory

H.-G. Moser*, S. Hass, C. Merck, J. Ninkovic, R. Richter, G. Valceanu Max-Planck-Institut für Physik, Föhringer-Ring 6, D-80805 Munich, Germany MPI Halbleiterlabor, Otto-Hahn-Ring 6, D-81739 Munich, Germany

Advanced Back-Illuminated Silicon Photomultipliers With Surrounding P+ Trench

Publisher: IEEE Cite This PDF

Haifan Hu; Ying Wang ; Penghao Liu; Xiubo Qin; Junpeng Fang; Hongming Zhao; Zhe Ma; Jiatong Wei

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Full

Text Views

PRO and CONS

- ☐ Entrance window is free of metal grid, quenching resistance, Through Silicon Vias:
 - ✓ Better Fill Factor
 - ☐ No need of Vias allows small SPAD size:



- √ High Dynamic range
- ✓ Better Radiation Tollerance
- ☐ All the contacts are on one side:



- ✓ Easy to couple Read Out Chip with bump bonding
- ✓ Natural to build monolithic Sensor + Electronics

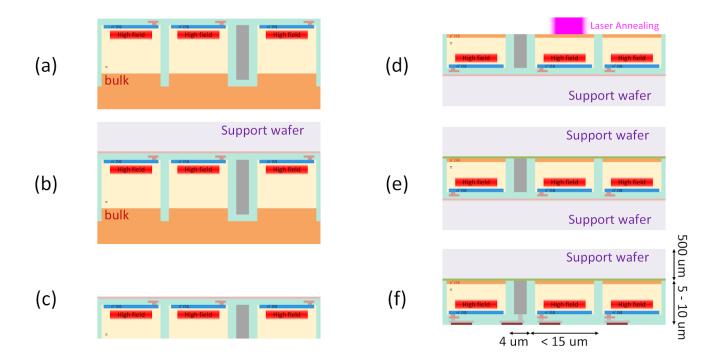


- No metallization in Entrance Window:
 - ✓ More difficult to control CrossTalk and AfterPulse



Sensor Development

- ☐ Microfabrication process deeply revised for the BSI
 - Start from the front side
 - Remove the bulk and laser annealing
 - Interconnection pads on the front side
- ☐ Test prototypes in FBK and Bologna also in liquid Nitrogen



- a) Build new cell
- b) Attach Support Wafer on Front side
- c) Remove completely Silicon bulk
- d) Laser annealing on backside thin dopant
- e) Attach Support Wafer on Backside
- f) Remove Support wafer from Back side



Sensor Development

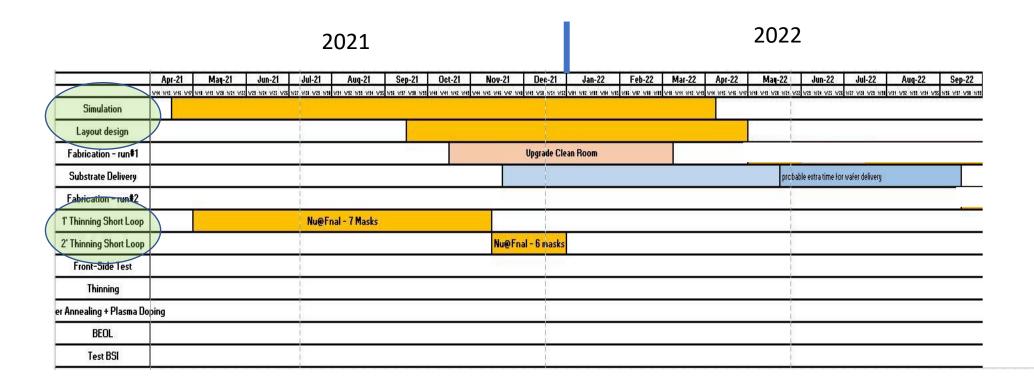
- Most critical processes:
 - 1. Design new cell (must limit Crosstalk, AfterPulse, Dark Count rate)
 - 2. Bulk removal (keeping flat surface: < 1 μm)
 - Laser annealing (in outsourcing)

- ☐ Delay of over 1 year wrt original plan due to:
 - COVID
 - upgrade of FBK clean room
 - Queue of projects at FBK



DONE in 2021(Apr)-2022 (Sept)

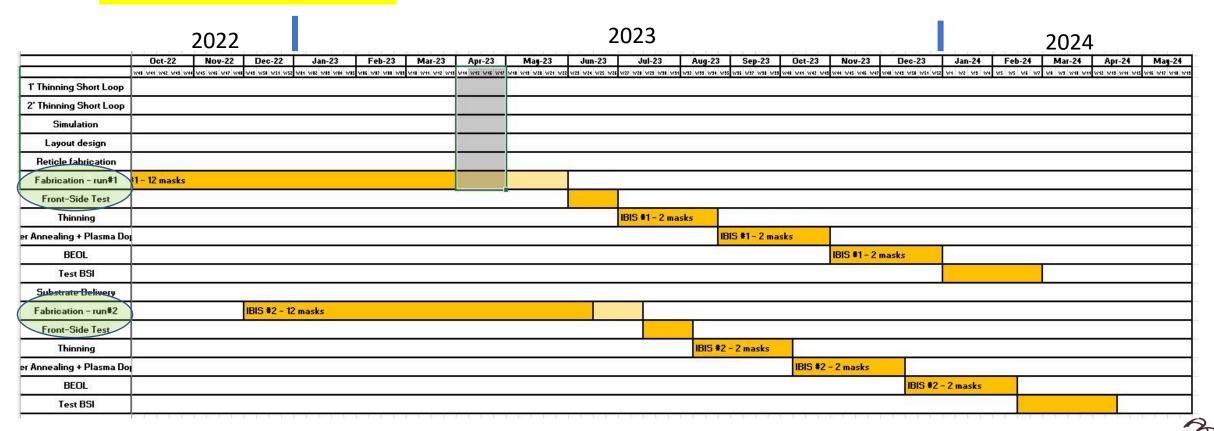
- ☐ Thanks to availability of a standard run from CSN 2 (Nu_at_FNAL):
 - Process 1. (new cell) and 2. (thinning) were completed (13 masks = 30 kE)



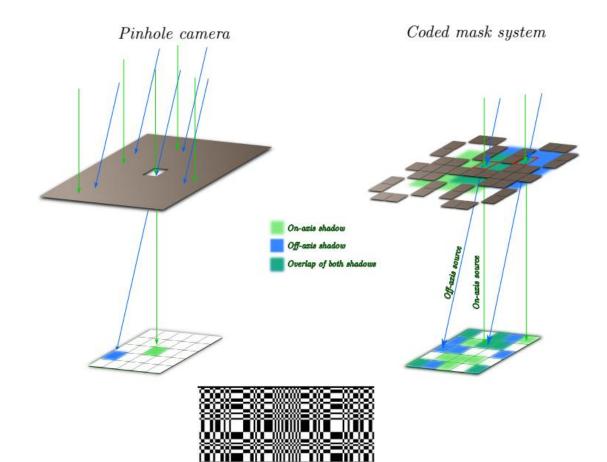


Where we are

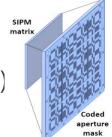
- ☐ 2 IBIS R&D run (2x45 kEuro) started in autumn 2022
 - First Front Side (with BSI cell) in June 2023
 - First Back Side Jan 2024



Optics development

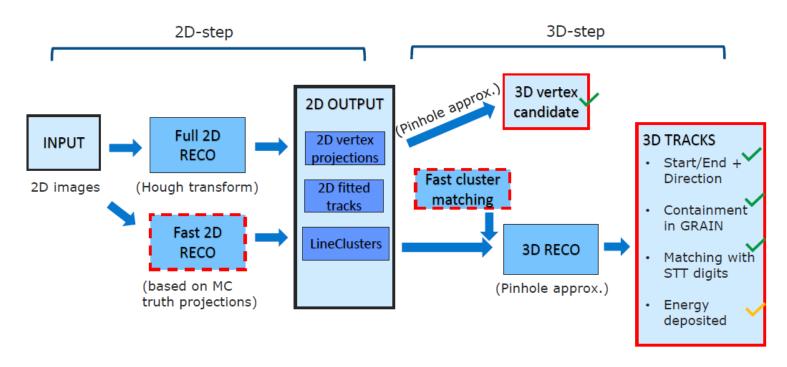


- Coded Aperture mask techniques were developed as the evolution of a single pinhole camera
 - matrix of multiple pinholes to improve light collection and reduce exposure time
- Image formed on sensor is the superimposition of multiple pinhole images.
- Advantages
 - Good light transmission (50%)
 - Good depth of field
 - Small required volume





Simulation

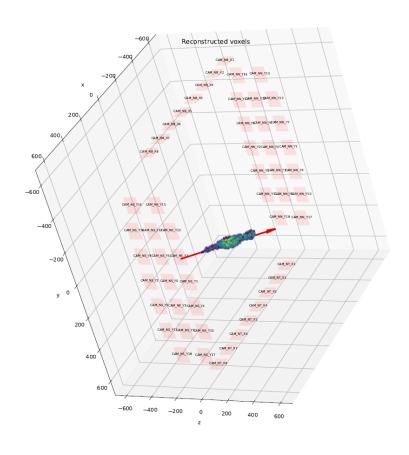


- ☐ Simulate interaction of radiation in Liquid Argon (and scintillator)
 - Photon generation and propagation (Geant4)
- ☐ Interaction with Masks or Lens or Mirror
- ☐ Determine number of photons on sensor
 - -> requirements for photo-sensor

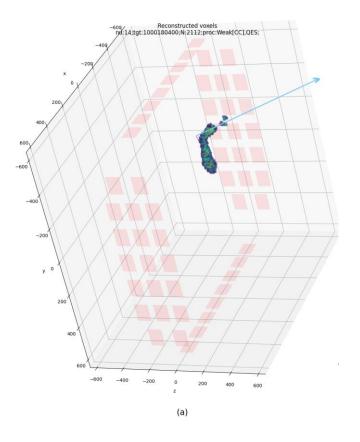


Examples

• Simulations of Coded Aperture masks with 3D reconstruction algorithm in LAr:



Cosmic Muon

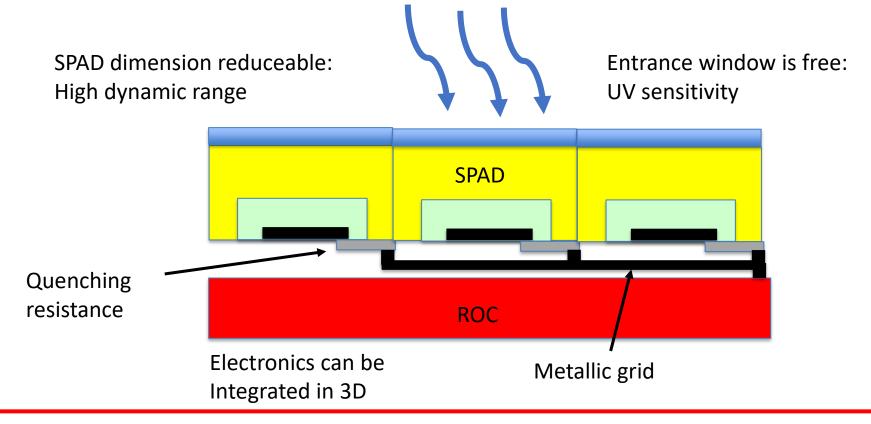


Neutrino Interaction (proton + muon)



Electronics

- ☐ As a first step of 3D integration, the design of INFN-Torino foresee a ReadOut Chip (ROC) based on the "Alcor" ASIC:
 - one channel in 440x440 um2
 - mini-SiPM by grouping SPADS so that the size correspond to one channel
 - chip bonding



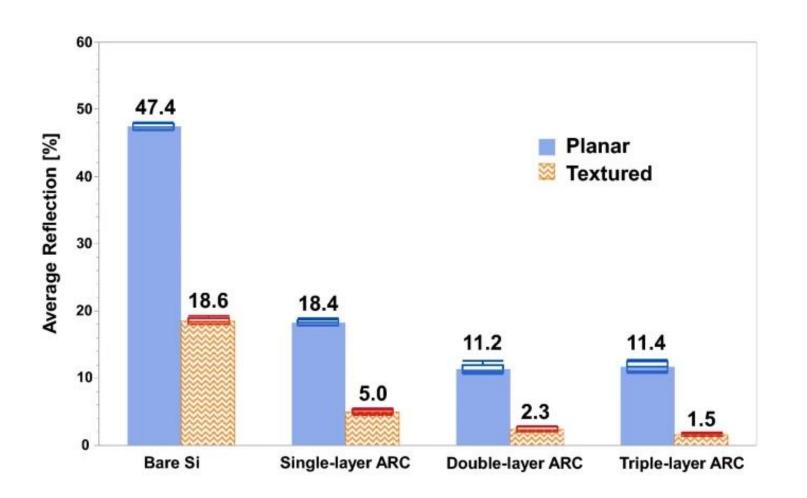
Conclusion

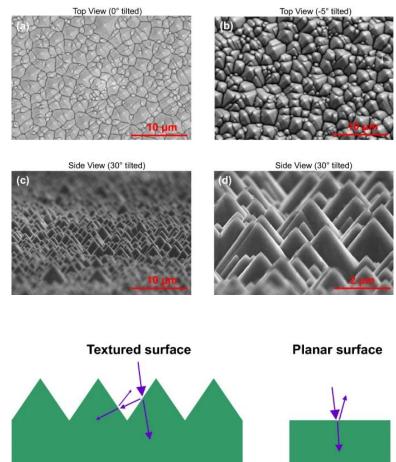
- ☐ Hopefully next June we will have the new cell (in FSI) to be tested
- ☐ Beginning of 2024 we will have the first BSI SiPM produced by FBK
- ☐ Simulation and reconstruction software are very advanced
- ☐ Electronics will benefit of the experience gained with Alcor chip
- □ IBIS ended in 2022, but the original budget for runs (90 kEuro) was granted in 2023 [requests for local services: Electronic Lab 3 mu (test boards etc..)]
- ☐ In total we invested about 120 kEuro to push the R&D in FBK on BSI and IBIS SiPM will be the first device ever produced
- ☐ We would like to continue to push this development to complete maturity: many groups in Italy are now interested on this technology. If we reach a critical mass we could propose a bigger project (CSN5 Call??)......

Thanks for attention!



ARC with textured surface







Scale prototype

- Use commercial products to build a prototype and corresponding simulation
- Allows tuning of free parameters
- Verify optics and technical issues



